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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO | | |
|--|-----------------|----------------------|-------------------------|-----------------|--|--|
| 10/710,847 | 08/06/2004 | Anil K. Chinthakindi | BUR920040112US1 | 6756 | | |
| 45601 7 | 7590 01/25/2006 | | EXAMI | EXAMINER | | |
| SCULLY, SCOTT, MURPHY & PRESSNER | | | CHIU, TSZ K | | | |
| 400 GARDEN CITY PLAZA GARDEN CITY, NY 11530 | | | ART UNIT | PAPER NUMBER | | |
| | | • | 2822 | | | |
| | | | DATE MAILED: 01/25/2006 | • | | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| Office Action Summary | | Applic | ation No. | Applicant(s) | Applicant(s) | | | | |
|--|--|--|---|--|--------------|----|--|--|--|
| | | 10/710 | ,847 | CHINTHAKINDI E | T AL. | M | | | |
| Office Action Summary | | | ner | Art Unit | | | | | |
| | | Tsz K. | | 2822 | | | | | |
| Period fo | The MAILING DATE of this communi or Reply | cation appears on | the cover sheet wi | th the correspondence ac | idress | | | | |
| WHIC - Exter after - If NO - Failu Any | ORTENED STATUTORY PERIOD FOR CHEVER IS LONGER, FROM THE MANSIONS OF THE MANSIO | AILING DATE OF of 37 CFR 1.136(a). In no unication. In the total period will apply an will, by statute, cause the | THIS COMMUNIC event, however, may a red d will expire SIX (6) MON application to become AB | CATION. sply be timely filed THS from the mailing date of this c ANDONED (35 U.S.C. § 133). | | | | | |
| Status | • | | | | | | | | |
| 1)⊠ | Responsive to communication(s) filed | d on 06 August 20 | 004. | | | | | | |
| 2a)□ | This action is FINAL . 2b)⊠ This action is non-final. | | | | | | | | |
| 3) Since this application is in condition for allowance except for formal matters, prosecution as to the | | | | | | | | | |
| , | closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. | | | | | | | | |
| Diamoniti | · | · | • | • | | | | | |
| · | on of Claims | | | | | | | | |
| . — | ☑ Claim(s) <u>1-40</u> is/are pending in the application. | | | | | | | | |
| | 4a) Of the above claim(s) <u>11-40</u> is/are withdrawn from consideration. | | | | | | | | |
| · | Claim(s) is/are allowed. | | | | | | | | |
| · | Claim(s) <u>1-10</u> is/are rejected. | | | | | | | | |
| | Claim(s) is/are objected to. | | | | | | | | |
| 8)[] | Claim(s) are subject to restrict | ion and/or electio | n requirement. | | | | | | |
| Applicati | on Papers | | | | | | | | |
| 9) | The specification is objected to by the | Examiner. | | | | | | | |
| • — | The drawing(s) filed on is/are: | | b) ☐ objected to | by the Examiner. | | | | | |
| ٠٠,٣ | Applicant may not request that any object | | | | | | | | |
| | Replacement drawing sheet(s) including | | | | FR 1.121(d) |). | | | |
| 11) | The oath or declaration is objected to | | _ | | | | | | |
| | | by the Examiner. | | | | | | | |
| • | ınder 35 U.S.C. § 119 | | ٠ | | | | | | |
| a) | Acknowledgment is made of a claim f All b) Some * c) None of: 1. Certified copies of the priority of 2. Certified copies of the priority of 3. Copies of the certified copies of application from the Internation of the attached detailed Office action | documents have to documents have to for the priority documand the priority documents and the priority documents are the priority documents and the priority documents are the priorit | neen received. neen received in A nments have been Rule 17.2(a)). | pplication No received in this National | Stage | | | | |
| 2) Notice | t(s) te of References Cited (PTO-892) te of Draftsperson's Patent Drawing Review (Pimation Disclosure Statement(s) (PTO-1449 or the No(s)/Mail Date 8/6/04. | | Paper No(s | Summary (PTO-413) s)/Mail Date nformal Patent Application (PTo | O-152) | | | | |
| | | | | | | | | | |

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DETAILED ACTION

Election/Restrictions

Applicant's election without traverse of group I, claims 1-10, in the reply filed on 12/28/05 is acknowledged.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claim 1-3, 5-8, and 10 are rejected under 35 U.S.C. 102(b) as being anticipated by Wu (6,586,311).

With respect to claim 1, Wu discloses a semiconductor substrate including at least one front-end-of-the-line device (Figure 4) located on a surface thereof, at least one resistor (Figure 8) located on, or in close proximity to, said surface of said semiconductor substrate (400, For example Fig. 8), said at least one resistor (Figure 8) comprising at least a conductive metal (600, For example Fig. 8), and first level of metallization (700, For example Fig. 9) above said at least one resistor.

With respect to claim 2, Wu discloses a trench isolation region (460, For example Fig. 9) in said semiconductor substrate (400, For example Fig. 9), said at least one resistor (640, 540, For example Fig. 9) is positioned on said trench isolation region (460, For example Fig. 9).

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With respect to claim 3, Wu discloses conductive metal comprises Ta, TaN, Ti, TiN, W, WN, Nicr, Sicr or a metal silicide (Column 7, lines 9).

With respect to claim 5, Wu discloses conductive metal has a thickness from about 20 to about 50 nm (column 5, lines 46-48 and 54-56).

With respect to claim 6, Wu discloses an etch stop layer (540, For example Fig. 10) located beneath said conductive metal.

With respect to claim 7, Wu discloses etch stop layer has a thickness from about 20 to about 50 nm (column 5, lines 30-32).

With respect to claim 8, Wu discloses a dielectric material (450, For example Fig. 4) on said at least one resistor.

With respect to claim 10, Wu discloses at least one FEOL device comprises a field effect transistor, a bipolar transistor, a BiCMOS device, or a passive device (920 as drain/source, 915 as gate of the transistor, For example Fig. 10).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 4 is rejected under 35 U.S.C. 103(a) as being unpatentable over Wu in view of Osanai et al. (6,777,752).

With respect to claim 4, Wu discloses the invention set forth in claim 1 but did not disclose conductive metal comprises TiN, TaN, Nicr or Sicr.

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Osanai discloses conductive metal comprises TiN, TaN, Nicr or Sicr (Column 50, lines 12-19).

Since Wu and Osanai are both from the same field of manufacturing a semiconductor device, the purpose disclosed by Osanai would have been recognized in the pertinent art of Wu.

Therefore, it would have been obvious at the time the invention was made to a person having ordinary skill in the art to have use Osanai Titanium nitride in Wu conductive member, Titanium silicide, for the purpose of using titanium nitride an excellent combination of performance properties, attractive appearance, and safety, also maintaining sharp edges or corners prevent galling, seizing or cold-welding and withstands high temperatures.

Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over Wu in view of Erdeljac et al. (5,554,873).

With respect to claim 9, Wu discloses the invention set forth in claim 1 but did not disclose first level of metallization comprises an inter-level dielectric material having contact openings that are filled with a conductive material.

Erdeljac discloses first level of metallization (54, For example Fig. 11) comprises an inter-level dielectric material (52, For example Fig. 11) having contact openings that are filled with a conductive material (54, For example Fig. 11).

Since Wu and Erdeljac are both from the same field of manufacturing a semiconductor device, the purpose disclosed by Erdeljac would have been recognized in the pertinent art of Wu.

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Therefore, it would have been obvious at the time the invention was made to a person having ordinary skill in the art to have use Erdeljac contact metal with a dielectric material opening in Wu invention for the purpose of having a contact metal with dielectric layer in between can prevent short circuit when connecting the device and also less complicated to reach to the device and with the contact metal it can have more layer forming on top of the device so that more space can be use.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tsz K. Chiu whose telephone number is 517-272-8656. The examiner can normally be reached on 0800 to 1700.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra V. Smith can be reached on 571-272-2429. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TKC January 19, 2006 ZANDRA V. SMITH SUPERVISORY PATENT EXAMINER Application/Control Number: 10/710,847

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